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APPLICATION NO. FILING DATE FIRST NAMED INVENTOR ATTORNEY DOCKET NO CONFIRMATION NO. 09 903,760 07.13 2001 Yoshifumi Takata 50090-318 7590 05 07 2003 McDERMOTT, WILL & EMERY FXAMINER 600 13th Street, N.W. MITCHELL, JAMES M Washington, DC 20005-3096 ART UNIT PAPER NUMBER 2827

DATE MAILED: 05-07-2003

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)
Office Action Summary	09/903,760	TAKATA ET AL.
	Examiner	Art Unit
	James Mitchell	2827
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply		
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status		
1) Responsive to communication(s) filed on <u>14</u>	lanuary 2003 .	
	is action is non-final.	
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213. Disposition of Claims		
4) Claim(s) 9.11 and 12 is/are pending in the app	olication.	
4a) Of the above claim(s) is/are withdrawn from consideration.		
5) Claim(s) is/are allowed.		
6)⊠ Claim(s) <u>9,11 and 12</u> is/are rejected.		
7) Claim(s) is/are objected to.		
8) Claim(s) are subject to restriction and/or election requirement.		
Application Papers		
9) The specification is objected to by the Examiner	r.	
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.		
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).		
11)☐ The proposed drawing correction filed on is: a)☐ approved b)☐ disapproved by the Examiner.		
If approved, corrected drawings are required in reply to this Office action.		
12)☐ The oath or declaration is objected to by the Examiner.		
Priority under 35 U.S.C. §§ 119 and 120		
13) Acknowledgment is made of a claim for foreign	priority under 35 U.S.C.	§ 119(a)-(d) or (f).
a) ☐ All b) ☐ Some * c) ☐ None of:		
1. Certified copies of the priority documents have been received.		
2. Certified copies of the priority documents have been received in Application No		
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 		
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).		
a) The translation of the foreign language provisional application has been received.		
15)⊠ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.		
Attachment(s)		
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 03/2	5) Notice of I	Summary (PTO-413) Paper No(s) nformal Patent Application (PTO-152)
S Patent and Trademark Office		

DETAILED ACTION

Claim Objections

Claim 9 is objected to because of the following informalities: grammatical error by the use of the word "form" in Line 7. Appropriate correction is required.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claim 9, 11 and 12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yano (U.S 6,022,804) in combination with Sato (000266749B1) and Tottori (US 5,930,674).

Sato (Fig 2A-2c; Col. 1, Lines 23-39) discloses a method of forming a semiconductor device comprising the steps of: forming a silicon oxide first interlayer

(102) on a semiconductor substrate (not labeled), forming a plurality of openings (103) in said first interlayer insulating film, forming a conductor (105) on said first interlayer insulating film so as to fill said openings and removing said conductor film from said surface of said first interlayer insulating film through chemical etching forming conductor plugs ("contacts") from said conductor film utilizes CMP after an etch step (shown in Fig 1; Column 3, Lines 1-15) comprising: removal of a conductor from insulating film through a chemical etch ("RIE") to form a plug ("metal contact") from said conductor filled in an opening and then leveling (Column 4, Lines 6-12) the surface of said insulating film from which the conductor film has been removed until the surface of the insulating film and plugs are flush by CMP.

Sato does not appear to disclose various sequential steps such as forming a second and third interlayer with openings to penetrate said second and third layer, or that the contacts are comprised of a polycrystalline silicon.

However Yano (Fig 1(a)-2) discloses sequential steps of forming a second interlayer insulating film (22) on said first interlayer insulating film, forming a wiring pattern (42B) on said second insulating film, forming a third interlayer insulating film (23) on said second insulating film so as to cover said wiring pattern and forming a plurality of openings so as to penetrate said second and third interlayer insulating film respectively to said conductor plug, and forming a plurality of interconnect conductors (43B) in said openings so as to be electrically connected to each of said conductor plugs.

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It would have been obvious tone of ordinary skill in the art to sequentially form a second interlayer insulating film on said first interlayer insulating film of Sato with conductor plugs formed therein, forming a wiring pattern on said second insulating film, forming a third interlayer insulating film on said second insulating film so as to cover said wiring pattern and forming a plurality of openings so as to penetrate said second and third interlayer insulating film respectively to said conductor plug, and forming a plurality of interconnect conductors in said openings so as to be electrically connected to each of said conductor plugs in order to provide a multilayer stacked connection as required by Sato (Col. 6, Lines 23-25).

Tottori utilizes a polycrystalline silicon film to form a plug (Fig 1, Item 7; Abstract).

It would have been obvious to one of ordinary skill in the art to incorporate a polycrystalline silicon to the interconnect structure of Sato and Yano in order to provide a conductive contact providing increased reliability as taught by Tottori (Column 4, Lines 38-40).

Response to Arguments

Applicant's arguments with respect to claims 9, 11 and 12 have been considered but are most in view of the new ground(s) of rejection.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to James Mitchell whose telephone number is (703) 305-0244. The examiner can normally be reached on M-F 10:30-8:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David L. Talbott can be reached on (703) 305-9883. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 305-3432 for regular communications and (703) 305-3230 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

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jmm

May 5, 2003

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Marie Tollie

DAVID L. TALBOTT
WERVISORY PATENT EXAMINER
SCHOOL OGY CENTER 2800